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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
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21567 73	590 11/22/2004		EXAMINER	
WELLS ST. JOHN P.S. 601 W. FIRST AVENUE, SUITE 1300			MEEKS, TIMOTHY HOWARD	
SPOKANE, WA 99201			ART UNIT	PAPER NUMBER
			1762	

DATE MAILED: 11/22/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		me
	Application No.	Applicant(s)
Office Astion Occurrence	10/666,025	BASCERI ET AL.
Office Action Summary	Examiner	Art Unit
	Timothy H. Meeks	1762
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be ting within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	mely filed ys will be considered timely. n the mailing date of this communication. ED (35 U.S.C. § 133).
Status		
Responsive to communication(s) filed on 2a) ☐ This action is FINAL . 2b) ☒ This 3) ☐ Since this application is in condition for allowar closed in accordance with the practice under E	action is non-final. nce except for formal matters, pro	
Disposition of Claims		
4) ☐ Claim(s) 1-11 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-11 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	wn from consideration.	
Application Papers		
 9) The specification is objected to by the Examiner 10) The drawing(s) filed on <u>17 September 2003</u> is/a Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Example 1 	are: a)⊠ accepted or b)⊡ object drawing(s) be held in abeyance. Section is required if the drawing(s) is obj	e 37 CFR 1.85(a). Djected to. See 37 CFR 1.121(d).
Priority under 35 U.S.C. § 119		
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priori application from the International Bureau * See the attached detailed Office action for a list of 	s have been received. s have been received in Applicati ity documents have been receive ı (PCT Rule 17.2(a)).	ion No ed in this National Stage
Attachment(s)		
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 20030917	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P	

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1 and 10 are rejected under 35 U.S.C. 102(e) as being clearly anticipated by Taguwa (6,404,058).

Taguwa discloses a plasma enhanced chemical vapor deposition (PECVD) method of forming a titanium silicide comprising layer over a substrate using a reactive gas comprising TiCl₄ and at least one silane comprising providing a substrate to a PECVD chamber, first feeding TiCl₄ to the chamber without feeding silane to the chamber for a first period of time to deposit a titanium layer, after said first feeding, feeding TiCl₄ and silane to the chamber for a second period of time to deposit a PECVD titanium silicide layer (col. 4, line 65 to col. 5, line 30).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 2-4 and 6-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Taguwa.

Taguwa does not explicitly disclose that the pressure and temperature of the chamber are the same during the 1st and 2nd feedings or if the TiCl₄ flow rate is constant or different during the 1st and 2nd feedings. However, the conditions specified for temperature, pressure, and flow rate taught by Taguwa during the Ti layer deposition and titanium silicide layer deposition show that using the same pressure and temperature and either the same or different titanium flows to be operable for these steps, it would have been obvious to have used the pressures, temperatures, and flow rates as claimed with a reasonable expectation of their being suitable for depositing the desired layers.

Taguwa does not explicitly disclose the feeding time for the titanium layer deposition and titanium silicide deposition. However, because the disclosed thicknesses for the titanium silicide layer are larger than the titanium layer, it would have

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been obvious to deposit the titanium layer for less time than the titanium silicide layer to provide the desired thicknesses. Likewise, the claimed times for depositing the first layer would have been obviously achieved through routine experimentation based on the achieved deposition rates so as to achieve the desired thicknesses.

Claims 5 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Taguwa.in view of Kang et al. (6,174,809)

Taguwa discloses provision of reducing gas with the TiCl₄ in a plasma to form the titanium layer rather than providing TiCl₄ alone in the absence of plasma. However, because Kang discloses at the abstract and col. 2, lines 8-10 and 40-57 that providing a sacrificial metal layer such as aluminum and then providing TiCl₄ without a plasma at a temperature of 300-500°C is effective for providing a more conformal Ti layer in a contact layer than that produced by a CVD process, it would have been obvious to have so provided the Ti layer to achieve a more conformal layer in the contact hole.

Double Patenting

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

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Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1-11 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-17 of U.S. Patent No. 6,586,285. Although the conflicting claims are not identical, they are not patentably distinct from each other because the claims of '285 anticipate the instant broader, less comprehensive claims.

Claims 1-11 are rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-11 of U.S. Patent No. 6,734,051. Although the conflicting claims are not identical, they are not patentably distinct from each other because the claims of '051 differ only in that they do not recite feeding of TiCl₄ to deposit the Ti layer, however, because TiCl₄ is a well known precursor for CVD of Ti as evidenced by the art recited above, it would have been obvious to feed TiCl₄ for deposition of the Ti layer.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Timothy H. Meeks whose telephone number is (571) 272-1423. The examiner can normally be reached on Mon 6-6, T-Th 9-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Shrive P. Beck can be reached on (571) 272-1415. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Timothy H Meeks
Primary Examiner
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